## XP-002276627

AN - 1983-719810 [30]

A - [001] 013 038 04- 062 074 075 081 143 144 151 155 157 158 163 166 169 170 171 172 173 200 207 208 220 221 222 246 305 306 308 310 318 321 323 364 365 398 400 435 443 466 470 477 50& 506 509 511 512 516 523 53& 57& 597 609 658 659 688 721 725

**CPY - TEIJ** 

DC - A14 A23 A89 G06 P84

FS - CPI;GMPI

IC - G03G5/02; G03G7/00; G03G15/22

KS - 0004 0016 0037 0207 0212 0231 0486 1291 1292 1319 1321 1323 1325 1327 1329 1373 1375 1377 1462 2209 2216 2274 2275 2321 2483 2500 2513 2551 2553 2559 2595 2656 2726 2804 2806 2808 3075 3083 3089 3178 3179

MC - A05-E01 A05-E06 A08-S04 A12-L05D G06-A03 G06-A07 G06-B01

PA - (TEIJ) TEIJIN LTD

PN - JP58102245 A 19830617 DW198330 007pp

PR - JP19810200097 19811214

XA - C1983-070332

XIC - G03G-005/02; G03G-007/00; G03G-015/22

XP - N1983-129660

- AB J58102245 Film comprises (A) a base layer, opaque film of (a1) aromatic polyester or (a2) aromatic polycarbonate having a cloudiness of 50% or more and (B) layer which is formed on one or both surfaces of (A) and has a surface specific resistance of 10 power 9 to 10 power 15 Ohms. Pref. binder component in (B) is polyester resin and/or acrylic resin.
  - Pref. (a1) is that produced from terephthalic acid or 2,6-naphthalene dicarboxylic acid as acid component and 2-6C straight chain aliphatic glycol as diol component and is opt. copolymerised with below 10 mol.% of a copolymerising component. Pref. (b) has intrinsic viscosity of 0.3-1.0 (0.40-0.65) in methylene chloride at 25 deg.C.
  - Copy produced from the film is sharp and is easy to ready. Since dust does not electrostatically stick to the film, the film has good transferring properties.

AW - POLYACRYLIC RESIN

**AKW - POLYACRYLIC RESIN** 

IW - FILM ELECTRON X-RAY PHOTOGRAPH OPAQUE FILM AROMATIC POLYESTER POLYCARBONATE LAYER SPECIFIED SURFACE RESISTANCE

IKW - FILM ELECTRON X-RAY PHOTOGRAPH OPAQUE FILM AROMATIC POLYESTER POLYCARBONATE LAYER SPECIFIED SURFACE RESISTANCE

NC - 001

OPD - 1981-12-14

ORD - 1983-06-17

PAW - (TEIJ ) TEIJIN LTD

TI - Film for electron- X=ray photography - has opaque film of aromatic polyester or polycarbonate, and layer with specified surface resistance